## Supporting Information

## Stabilizing the Chemistry of NiO<sub>x</sub> in Perovskite Solar Cells to Pass the Damp Heat Test

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Figure S1: Absorptance spectra of NiO<sub>x</sub>, O<sub>2</sub>-NiO<sub>x</sub> and O<sub>2</sub>-Cs:NiO<sub>x</sub>. NiO<sub>x</sub> (red curves) O<sub>2</sub>-NiO<sub>x</sub> (green curves) and O<sub>2</sub>-Cs:NiO<sub>x</sub> (blue curves) films before (solid lines) and after annealing at 300°C in ambient air (dashed lines).



Figure S2: J-V parameters of as-deposited PSCs for NiO<sub>x</sub> and O<sub>2</sub>-Cs:NiO<sub>x</sub>. NiO<sub>x</sub> (150 sccm Ar / 0 sccm Ar-O<sub>2</sub>, NiO<sub>x</sub> sputtering target) and O<sub>2</sub>-Cs:NiO<sub>x</sub> (120 sccm Ar / 30 sccm Ar-O<sub>2</sub> Cs:NiO<sub>x</sub> sputtering target).



**Figure S3: Photoluminescence spectra of NiO<sub>x</sub>/perovskite (red) and O<sub>2</sub>-Cs:NiO<sub>x</sub>/perovskite (blue) films coated on glass/ITO substrates.** Fresh samples are represented with dashed lines while aged samples (after one week in N<sub>2</sub> at 85°C) are represented with solid lines.



**Figure S4: J-V performances of 1 cm<sup>2</sup> semi-transparent PSCs based on 20 nm NiO<sub>x</sub> and O<sub>2</sub>-Cs:NiO<sub>x</sub> at different times of DH testing.** *a) Jsc, b) FF, c) Voc, d) Eff. To show statistics, 14 cells from 4 different batches are plotted here. The active area is 1 cm<sup>2</sup>.* 

**Note on Figure S4**: DH = -100h corresponds to the J-V measurement done on the as-finished device, whereas DH = 0h refers to the measurement after encapsulation. Right after the encapsulation, the devices show lower efficiencies due to lower J<sub>SC</sub> and V<sub>OC</sub>. This degradation caused by the encapsulation process is reversible after a few hours in the DH chamber, as it can be seen in Figures S4a and c. In more details, after encapsulation (DH = 0h), the device efficiency dropped by around 0.5 to 1% due to a decrease in J<sub>SC</sub>. This J<sub>SC</sub> variation could be caused by a combination of perovskite degradation due to the lamination process and the reflection of light at the front glass interface. After the first 160 hours in DH, the device efficiency increases as a result of a V<sub>OC</sub> enhancement of up to 100 mV. The origin of this large increase in V<sub>OC</sub>, observed in NiO<sub>x</sub>-based devices (with and without an organic interlayer at the interface), and accompanied by an increased PL is not clear. However, it could be explained by the removal of Ni<sup>3+</sup> traps at the interface during aging.



**Figure S5: FF of NiO<sub>x</sub>/MeO-2PACz-based PSCs presented in Figure 2 during damp heat testing.** *After (a) encapsulation, (b) 1000 h and (c) 2000 h in DH chamber, for different HTMs. J-V of the devices after 2000h of DH are inserted in the (c).* 



**Figure S6: J-V parameters of NiO**<sub>x</sub>/**MeO-2PACz-based PSCs presented in Figure 2 as a function of DH aging:** *a) efficiency, b) Voc, c) FF, d) Jsc and e) photos of each cell after more than 5100h in the DH chamber.* 



Figure S7: J-V parameters of PSCs based on NiO<sub>x</sub> and O<sub>2</sub>-NiO<sub>x</sub> during light soaking at 35°C and open-circuit conditions: a) Efficiency, b)  $J_{SC}$ , c)  $V_{OC}$  and d) FF of PSCs at different times during the light soaking test under 1 sun illumination,  $N_2$  flow, 35°C and open-circuit conditions. Active area 1.04 cm<sup>2</sup>.

Since excess  $PbI_2$  can cause perovskite degradation under light and heat [1], a perovskite solution approaching stoichiometric conditions (0.7%  $PbI_2$  excess) was used for the light soaking degradation tests.



**Figure S8: Atomic concentration of Ni, O, and Cs determined by STEM EDX for NiO<sub>x</sub> and O<sub>2</sub>-Cs:NiO<sub>x</sub> 20 nm films.** For both materials, EDX measurements were done on both as-deposited and annealed films. Annealing was done in air at 300°C for 30 min.



**Figure S9: Microstructure of NiOx and O2-Cs:NiOx thin films.** *a)* STEM bright-field image of annealed NiOx and b) O2-Cs:NiOx film.



**Figure S10: AFM images of both annealed NiOx (left) and O<sub>2</sub>-NiO<sub>x</sub> (right) films.** *The roughness of the O<sub>2</sub>-NiO<sub>x</sub> is two times lower than the one of the NiO<sub>x</sub>. This result coincides with the observation that O<sub>2</sub>-NiO<sub>x</sub> is more compact thanks to improved stoichiometry (O<sub>2</sub>-NiO<sub>x</sub>=1.06, resulting in fewer Ni<sup>3+</sup> species and Nivacancies) as well as a longer sputtering deposition.* 



**Figure S11: Ni 2p XPS surface analysis and deconvolution for each Ni oxidation state (Ni<sup>0</sup>, Ni<sup>2+</sup> and Ni<sup>3+</sup>) for NiO<sub>x</sub>, O<sub>2-</sub> NiO<sub>x</sub> and O<sub>2</sub>-Cs:NiO<sub>x</sub> films. Ni 2p envelopes, Ni<sup>2+</sup> and Ni<sup>3+</sup>peaks deconvoluted for each a) fresh and b) aged HTM are plotted. Table c) presents the integrated values for each contribution, in the different HTMs, before and after aging at 85°C in an inert atmosphere. The Ni<sup>0</sup> contribution in the NiO<sub>x</sub> film is shown by an arrow.** 



<b>c</b> )	Sample Names	Ni 2p Ni <sup>2+</sup> (%)	Ni 2p Ni <sup>3+</sup> (%)	O 1s NiO %	O 1s defects %	O 1s orgs %
	NiO <sub>x</sub> fresh	23	20	31	16	10
	O <sub>2</sub> -NiO <sub>X</sub> fresh	35	9	33	11	10
	O <sub>2</sub> -Cs:NiO <sub>X</sub> fresh	36	11	31	14	7
	NiO <sub>x</sub> aged	22	13	27	16	22
	O <sub>2</sub> -NiO <sub>X</sub> aged	25	11	29	16	18
	O <sub>2</sub> -Cs:NiO <sub>X</sub> aged	25	14	31	17	14

**Figure S12: XPS analysis of O 1s spectra for NiOx, O2-NiOx, and O2-Cs:NiOx surfaces before and after aging at 85°C.** *a) O 1s spectra of fresh samples and (b) aged one. Each O peak contribution is plotted in the same graph to highlight the shifts. Table c) presents the deconvoluted values obtained for each O and Ni contributions.* 

## **References:**

[1] F. Fu, S. Pisoni, Q. Jeangros, J. Sastre-Pellicer, M. Kawecki, A. Paracchino, T. Moser, J. Werner, C. Andres, L. Duchêne, P. Fiala, M. Rawlence, S. Nicolay, C. Ballif, A. N. Tiwari, S. Buecheler, *Energy Environ Sci* **2019**, 12, 3074.